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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/613,951	07/11/2000	Robert G. Wendt	TPG 306 1942		
75	90 08/26/2005		EXAMINER		
Kolisch Hartwell Dickinson			PAIK, SANG YEOP		
McCormack & 1	Heuser				
Suite 200			ART UNIT	PAPER NUMBER	
520 S W Yamhi	Il Street		3742		
Portland, OR	97204				
			DATE MAILED: 08/26/2005	DATE MAILED: 08/26/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary		Application	n No.	Applicant(s)				
		09/613,95	1	WENDT ET AL.				
		Examiner		Art Unit				
		Sang Y. Pa	aik	3742				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply								
THE - Exte after - If the - If NO - Failu , Any	ORTENED STATUTORY PERIOD FOR MAILING DATE OF THIS COMMUNICA' nsions of time may be available under the provisions of 37 SIX (6) MONTHS from the mailing date of this communical period for reply specified above is less than thirty (30) do period for reply is specified above, the maximum statutor re to reply within the set or extended period for reply will, it reply received by the Office later than three months after the patent term adjustment. See 37 CFR 1.704(b).	TION. 7 CFR 1.136(a). In no eve ation. 1ys, a reply within the statury period will apply and will by statute, cause the appli	nt, however, may a reply be tin tory minimum of thirty (30) day expire SIX (6) MONTHS from cation to become ABANDONE	nety filed s will be considered timely. the mailing date of this communication. O (35 U.S.C. § 133).				
Status								
1) 又	Responsive to communication(s) filed or	n <i>04 April 2005</i> .						
•	This action is FINAL . 2b) ☐ This action is non-final.							
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is							
·	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.							
Disposit	on of Claims							
5)□ 6)⊠ 7)□	Claim(s) 36-66 is/are pending in the app 4a) Of the above claim(s) is/are w Claim(s) is/are allowed. Claim(s) 36-66 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction	vithdrawn from cor						
Applicat	on Papers							
9)[The specification is objected to by the Ex	xaminer.						
10)[10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
11)	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority (under 35 U.S.C. § 119							
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 								
Attachmen	t(s)							
	e of References Cited (PTO-892)		4) Interview Summary					
3) 🔲 Infon	e of Draftsperson's Patent Drawing Review (PTO-t mation Disclosure Statement(s) (PTO-1449 or PTC r No(s)/Mail Date		Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	atent Application (PTO-152)				

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 36, 38-40, 44 and 54 are rejected under 35 U.S.C. 103(a) as being unpatentable over Baron et al (US 4,401,052) in view of Akram et al (US 5,741,547) or Yoshioka et al (US 6,074,487).

Baron shows a vapor deposition diffusion system having a substrate strip moving through a evaporation chamber with three serially located heated manifolds made of graphite or boron nitride including substantially closed vessels where each manifolds has the first and second vessels and an array of vapor delivery nozzles creating a fog to uniformly deposit the source material to the substrate strip. Baron having the structure as claimed is capable of concurrently emitting a plurality of different source materials from the first and second vessels but does not show each vessel having different source materials that are emitting concurrently.

Akram shows that it is well known in the art to provide two different source materials that are combined to create a concurrently emitted reactant mixture for the chemical vapor deposition of such material onto a substrate. Yoshioka also shows a plurality of source materials that are mixed or combined to concurrently emit the mixture for the chemical vapor deposition.

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In view of Akram or Yoshioka, it would have been obvious to one of ordinary skill in the art to adapt Baron with the vessels having different source materials that can be combined to create the concurrently combined mixture for its chemical vapor deposition.

With respect to claim 40, Baron further shows a thermal shield such as a tantalum foil around the manifold. With respect to claim 54, Baron teaches that the deposition rate as well as uniformity of deposition depends with the geometry of the nozzle among other factors, and it would have been obvious to one of ordinary skill in the art to adapt the discharge opening of the nozzles within the claimed range or any other range that will meet the desired deposition rate and the uniformity.

3. Claims 37, 47-53 and 55 are rejected under 35 U.S.C. 103(a) as being unpatentable over Baron in view of Akram or Yoshioka as applied to claims 36, 38-40, 44 and 54 above, and further in view of Chow (US 5,031,229).

Baron in view of Akram or Yoshioka discloses the device claimed except having a heating system to maintain the nozzle at a temperature higher than the source material.

Chow shows an evaporating manifold or vessel made of boron nitride with a lid having a plurality of nozzle that is provided with an electrical U-shaped heating system for heating the nozzle at the temperature higher than the body of the vessel (also, see column 6, lines 6-33).

In view of Chow, it would have been obvious to one of ordinary skill in the art to adapt Baron, as modified by Akram or Yoshioka, with the heating system to provide a higher temperature than the body of the vessel to keep the evaporated material from condensing.

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With respect to claim 50, it would have been obvious to one of ordinary skill in the art to modify the distance between the nozzles within the claimed range to modify the deposition rate and the uniformity of the deposition surface.

4. Claims 41-43, 45 and 46 are rejected under 35 U.S.C. 103(a) as being unpatentable over Baron in view of Akram or Yoshioka and Chow as applied to claims 36-40, 44, 47-55 above, and further in view of Finicle (US 5,158,750).

Baron in view of Akram or Yoshioka and Chow discloses the device claimed except plural insulation layers.

Finicle shows a vessel or crucible having a thermal control shield around the vessel including an outer shell made of ceramic material such as graphite and a plurality of insulation layers. In view of Finicle, it would have been obvious to one of ordinary skill in the art to adapt Baron, as modified by Akram or Yoshioka and Chow, with the plurality of insulation layers to further protect the vessel.

5. Claims 56-66 are rejected under 35 U.S.C. 103(a) as being unpatentable over Baron in view of Akram or Yoshioka and Chow as applied to claims 36-40, 44, 47-55 above, and further in view of Matsuda et al (US 5,571,749).

Baron in view of Akram or Yoshioka and Chow discloses the device claimed including the crucibles, the nozzles, the nozzle heating system, the thermal control shield except having a roll assembly to continuously supply a strip material.

Matsuda et al shows a roll assembly where a substrate strip is fed through an evaporation chamber for chemical deposition. In view of Matsuda et al, it would have been obvious to one of ordinary skill in the art to adapt Baron, as modified by Akram or Yoshioka and Chow, with a roll

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assembly to feed a strip for a continuous process of the vapor deposition having a substantially constant level to produce the desired deposition level since such level or velocity would be determinative how thick the deposition layer can be as taught by Baron (see column 5, lines 65-67).

Response to Arguments

- 6. Applicant's arguments with respect to claims have been considered but are moot in view of the new ground(s) of rejection.
- 7. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sang Y. Paik whose telephone number is 571-272-4783. The examiner can normally be reached on M-F (9:00-4:00) First Friday Off.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robin Evans can be reached on 571-272-4777. The fax phone number for the

organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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